UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/711,821	10/07/2004	Jean-Jacques Katz	MASLIAC-60	5820	
	7590 02/25/200 ON & EVANS, LLP (EXAMINER		
2700 CAREW	TOWER	PASCHALL, MARK H			
441 VINE STREET CINCINNATI, OH 45202			ART UNIT	PAPER NUMBER	
,			3742		
			MAIL DATE	DELIVERY MODE	
			02/25/2008	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)			
	10/711,821	KATZ ET AL.			
Office Action Summary	Examiner	Art Unit			
	Mark H. Paschall	3742			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence ad	dress		
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 16(a). In no event, however, may a reply be tim 11 apply and will expire SIX (6) MONTHS from 12 cause the application to become ABANDONEI	l. ely filed the mailing date of this co O (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on					
	-· action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the meri					
•	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.				
dissect in assertations with the practice and in	x parte quayre, 1000 0.D. 11, 10	0.0.210.			
Disposition of Claims					
4) ☐ Claim(s) 1-12 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-12 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or					
Application Papers					
9) ☐ The specification is objected to by the Examiner 10) ☑ The drawing(s) filed on <u>07 October 2004</u> is/are: Applicant may not request that any objection to the or Replacement drawing sheet(s) including the correction 11) ☐ The oath or declaration is objected to by the Examiner	a)⊠ accepted or b)⊡ objected drawing(s) be held in abeyance. See on is required if the drawing(s) is obj	37 CFR 1.85(a). ected to. See 37 CF	FR 1.121(d).		
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of	s have been received. s have been received in Application ity documents have been received (PCT Rule 17.2(a)).	on No d in this National	Stage		
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 10-7-2004.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te			

Application/Control Number: 10/711,821

Art Unit: 3742

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1,5,11 and 12 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Sigel et al 6569500'. Note that Sigel et al teaches surface modification of gloss surfaces using ionization via electron beam, to reduce the gloss, and use of scanning it taught, as claimed. See column5, first paragraph.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary.

Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor

Art Unit: 3742

and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 1-4,6-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sigel et al 6,569,500 in view of either Razavi 6,057,414 or Hahn et al 4,170,663.

Sigel et al teach the claimed invention and it is evident and inherent that plasma formation occurs via ionization of the nitrogen gas in Sigel et al via electron beam. In addition the patents to both Razavi and Hahn et al are applied for evidencing that plasma can be used for surface modification of polymer, and in view of these teachings it would have been obvious to modify the Sigel et al system to use specific plasma, thermal or cold, to effect the surface modification. Use of corona or scanning as per claims 4 and 5 is routine and obvious for the artisan. Use of shaping of the work prior to the treating as per claim 8, is likewise considered obvious, as is use of the end product in a vehicle environment.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Plester et al, Gibbs, I et al and Mahoney are cited for disclosing polymer modifying patents of interest to the instant invention

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mark H. Paschall whose telephone number is 571 272-4784. The examiner can normally be reached on 7am - 3pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robin Evans can be reached on 571-272-4777. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Mark H Paschall Primary Examiner Art Unit 3742

Mp

/Mark H Paschall/ Primary Examiner, Art Unit 3742.